# Summary of The Existing MR Beam Diagnostics for Use in Main Injector

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#### Abstract

A survey of the beam diagnostic devices reusable from the Main Ring and their existing operational limitations have been made. Possible places of using these devices in the Main Injector and their operational requirements have been investigated.

### Introduction

Previously a summary of the instrumentation requirements for the Main Injector has been given in MI76. In this report we revise them and give more specific MI requirements. Also summarize reusable beam diagnostic devices from the Main Ring and their existing limitations. Some qualitative facts regarding MI requirements are listed in the Table I. More details regarding the beam loss and beam intensity monitors are listed in tables II,III, and IV. For other devices the details are being determined.

Table I. Summary of Beam Diagnostic Instrumentation for the MI and Available devices from the MR.

Type/Location	Ring	P8	P1	A1	P2	Р3	Abort	Total	Available from MR*
POSITION MONITORS New FMI style Existing MR style Large Aperture <sup>1</sup>	203	34	14	14	7	32	3	203 104 5	To be built 216 To be built
Booster Style Tuned Detector		17	3		2	6		17	24(?)
LOSS MONITORS Ion Chambers	231	51	19	16	7	32	3	359	252
INT. MONITORS Resistive Wall <sup>2</sup> Toroid DCCT	2	2	1	1	2	1	1	2 8 1	2 6 1
High Gain RF slow spill Monitors	1		1					1	To be built
PROFILE MONITORS Flying Wire Wire Grid <sup>3</sup> Non-distructive <sup>4</sup>	2 6 2	4	2	2	2	3	2	2 21	3 19 To be built
DAMPERS <sup>5</sup> Horizontal Vertical	1 1							1 1	1
SCHOTTKY DET. Horizontal Vertical	1							1 1	Being Built Being Built
SCRAPERS <sup>6</sup> Horizontal Vertical		1 1						1 1	2 2

- \* Hardware can mostly be transferred to MI without any significant changes. The electronics will be modified to meet MI needs.
- <sup>1</sup> Large aperture beam position monitors are expected to be installed at the proton upstream end of the quads 101, 402, 522, 608, and 622 (i.e. adjacent to lambertsons in injection/extraction straight sections). These will be newly built.
- <sup>2</sup> Presently there are two resistive wall monitors: one old type nearly 2GHz dynamic range wall monitor and other one is new type 6GHz. We may have to build a new one to replace the old style monitors.
- <sup>3</sup> Presently there 19 wire chambers are available from MR. We are investigating alternative techniques like OTR monitors or thin film FLAG as beam profile monitors in the beam line.
- <sup>4</sup> Presently there are no non-distructive type beam profile monitors in the MR. We are investigating the feasibility of using residual gas MCP type beam profile monitors in Booster and MR as well as MI.
- <sup>5</sup> Damper plates and high level will be recycled from MR. The LL has to be modified.
- <sup>6</sup> There are two pairs of scrapers available; one from Booster to MR beam line and the other from MR. We plan to reuse a pair of scrapers in Booster to MI beam line. In MI we do not intend to use any scrapers.

## Beam Loss Monitors:

Table II. Loss Monitors: MR Status and MI Requirements

NUMBER OF BLM AVAILABLE FROM MR AND TYPE	MI REQUIREMENTS	COMMENTS
252	359(total)	Need additional 107 BLMs
Argon gas filled Tevatron type BLMs. These BLMs are linear in the range of 0.001rad to 100rad (instantaneous). The expected total dynamic range is \$\simeq 10^6\$ The lower limit is set by electronics.	Primarily BLMs are same as in MR. Should be capable of detecting 0.1% beam loss at full intensity (i.e. 0.1mRad/ft of MI ring at 8GeV and 1.0mRad/ft of MI ring at 150GeV) instantaneously.	The Electronics may have to be changed

Presently the MR BLMs are used to findout (qualitatively) where the MR beam is lost during the acceleration cycle. The electronics are setup in such a way that the integrated counts (radiation) will be reset to zero at the end of each MR cycle. The minimum radiation loss detected is about .5mRad on BLM display. Instantaneous losses directly from the tunnel at each BLM may be plotted.

# Resistive Wall Monitors:

Table III. Resistive Wall Monitors: MR Status and MI Requirements

# RESISTIVE WALL MONITORS AVAILABLE FROM MR AND TYPE	MI REQUIREMENTS	COMMENTS
2	2	One New style Resistive
One is old style, Length $\simeq$ 5in beam pipe: round, $3\frac{1}{4}$ in (?) Frequency range upto 2 GHz.	Two new style monitors are needed to measure .5-15ns bunches.	wall monitor will be built and . part of the electronics from old style resistive
One new style  Length $\simeq 1$ meter  beam pipe: round, $3\frac{1}{4}$ in dia.  Frequency range $4kHz$ - $6GHz$ .	(One for monitoring bunch structure during coalescing and other operations, and second for beam diagnostics studies.)	wall monitor can be used.

# Toroid and DCCT:

Table IV. Beam Intensity Monitors: MR Status and MI Requirements

#	NAME	PRESENT OPERATIONAL	MI OPERATIONAL	COMMENTS*
		CONDITION	REQUIREMENTS	
1.	-	These Monitors	Two Monitors are	
	M:BIM10	are in 8GeV Booster	needed in 8GeV	Can be used
	M:BIM50	to MR beam line.	beam line between	in MI
	4.75"ID	Beam PL = .15-1.59 $\mu$ sec,	Booster to MI.	
	1110 12	electronic OR =10-500mA.	Beam PL=.15-1.59 $\mu$ sec,	
		Presently:15mA-250mA.	electronic OR = 1-600mA.	
		This is in A11	Needed in MI	
2.	M:A11TRO	sector of MR to	to measure the intensity	Can be used
	6.5"ID	measure the intensity	of the transferred	in MI
		of the 8GeV beam	8GeV beam from	
		transferred from Booster.	Booster.	
		Beam PL = $.15-1.59\mu$ sec,	Beam PL = $.15$ -1.59 $\mu$ sec,	
		electronic $OR = 10-500 \text{mA}$ .	electronic OR = 1-600mA.	
		This is in		
3.	M:IBEAMS	A17 in sector of the	Needed to measure	Can be used
	M:IBEAMM	MR to measure	circulating beam	in MI
	M:IBEAM	circulating beam.	in MI.	
	6.5"ID	electronic OR	electronic OR	1
	(DCCT)	$=380\mu\text{A}-380\text{mA}.$	$= 140 \mu \text{A-}600 \text{mA}$	
		This monitor is in	Needed to measure	
4.	M:ABTINT	C0 Abort line.	MI40 aborted beam.	Can be used
		Beam PL $=.2-20\mu sec$ ,	Beam PL =.1-10 $\mu$ sec,	in MI.
		electronic OR =10-500mA	OR =10-640mA	

PL = Pulse Length, OR = Operating Range.

Table IV (continued)

#	NAME	PRESENT OPERATIONAL CONDITION	MI OPERATIONAL REQUIREMENTS	COMMENTS
5.	M:TOR100	This is in AP1 beam line (F17) to measure 8GeV (or 120GeV) pbar (or protons) from pbar source (or from MR). Beam PL = .2-20 \(\mu\)sec, electronic OR = 10-500 mA.	This is needed to measure 8GeV (or 120GeV) pbar (or protons) from pbar source (or from MI). Beam PL = .2-10 \mu sec, OR = 1-600mA. (5-6E12p/batch)	Continue to use in F17
6.	-	_	Two monitors are needed in beam lines P1 and P2 Beam PL= 10µsec, OR = 0.1-640mA for fixed target runs, OR = 0.1-35mA for collider runs, OR = 1E4-1E5p/s for Resonant extraction.	New
7.	-	-	One monitor is needed in beam line P3.  Beam PL= 10 \mu sec,  OR = 1E4-1E5 \mu/s for Resonant extraction.	New
8.			Needed in A1 beam line to measure pbar beam from MI to Tevatron. OP = 1-4mA, Beam PL = 1.6 \mu sec.	New

PL = Pulse Length, OR = Operating Range.

<sup>\*</sup> The required dynamic ranges of the beam intensity monitors in MI are larger in almost every case. Hence the electronics setup have to be changed.